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| Short Title (WEB) | Adjunct Faculty Position in Fashion Design (Apparel) |
| Full Title | Adjunct Faculty Position in Fashion Design (Apparel area) at the Fashion Institute of Technology at SUNY Korea |
| About Fashion Institute of Technology: | The Fashion Institute of Technology (FIT), an internationally renowned college of art and design, business and technology, of the State University of New York, invites nominations and applications for adjunct faculty positions in the Fashion Design program at the FIT at SUNY Korea in Songdo, Korea. The Fashion Institute of Technology, a part of the State University of New York, has been a leader in career education in art, design, business, and technology for nearly 70 years. With a curriculum that provides a singular blend of hands-on, practical experience, classroom study, and a firm grounding in the liberal arts, FIT offers a wide range of outstanding programs that are relevant to today's rapidly changing industries. Internationally renowned, the college offers two majors, and grants AAS degrees in Korea in Fashion Business Management and Fashion Design, preparing students for professional success and leadership in the global marketplace. |
| Department Statement: | The Fashion Design program provides the expertise students need to develop the skills necessary to become competitive, forward thinking graduates for positions in the fashion industry and related fields. The program offers a wide range of learning experiences through the rigorous AAS curriculum where they develop critical thinking, strong design aesthetics and technical abilities. Faculty members are industry professionals who draw on industry connections to provide students with an in-depth view of the fashion design industry. |
| Job Description: | The Fashion Design department is seeking a fashion design faculty member with relevant industry experience. The ideal candidate will be an established fashion designer with various levels of design leadership experience. The individual readily combines superior hands-on traditional and conceptual design approaches to develop and teach core AAS courses.  The successful candidate will be knowledgeable of successful fashion practices across a number of current methodologies and must possess strong design development and brand building expertise. In addition, a personal area of strength must be demonstrated, such as research and knowledge of fashion technology and innovation, fashion show presentations or exhibitions, and/or writing curriculum. The successful candidate will work collaboratively to establish and implement a vision that supports the strategic goals of the department and the college.  Ideal candidates will demonstrate expertise in the following areas:  • Conceptual development, collection/line building through expected technical skill sets for apparel prototype development.  • First-hand knowledge of the fashion design development, team and brand building processes with the ability to guide students in implementing these processes.  • Ability to synthesize and move readily between conceptual and established hands-on methodologies in the design development process.  • Active engagement with the current industry through professional experiences, scholarly research and/or expression through creative works. |
| Possible Teaching Courses | The successful candidate should be able to teach one or more of the following Fashion Design Technical courses:   * Sewing * Introductory Draping * Patternmaking * Structured Draping (jackets) |
| Minimum Qualifications | Candidates are required to have six (6) years of professional experience as a fashion designer. A Bachelor’s degree is required. Candidates are required to present a strong portfolio showcasing their professional work, inclusive of relevant press and/or industry acknowledgements. Excellent English oral and written communication skills. |
| Preferred Qualifications | Master's degree preferred. Three (3) years or more teaching experience in higher education is preferred. Preference will be given to candidates who possess several or all the above listed qualifications. |
| Specific  Competencies | Successful candidates will excel in the following areas:  **Globalism**   * Demonstrate ability to work within, and to support and maintain productive relationships in multicultural environments, and model inclusive behaviors for students. * Demonstrate awareness and values of sustainable design, applying those values to the design process that is environmentally and socially responsible.   **Instructional Design**  • Demonstrate ability to incorporate a variety of instructional delivery methods including the use of demonstrations and specific project assignments.  • Demonstrate ability to utilize technology and electronic information to deliver course materials to students.  • Demonstrate ability to be responsive to industry changes and/or practices including technology.  **Learning Enrichment**   * Possess the ability to inspire and encourage curiosity and creativity. * Demonstrate ability to create learning experiences that foster critical thinking and problem solving. * Utilize professional knowledge and experience for collaboration and teamwork within the classroom.   **Professionalism**   * Possess the ability to effectively speak on behalf of the department and/or college with industry supporters. * Participate actively in the fashion industry including current connections and/or membership in organizations. * Demonstrate a continued focus on creative and scholarly work specific to the discipline. * Demonstrate strong leadership, self-motivation and team player qualities.   **Technology**   * Demonstrate proven experience and commitment to maintaining updated technological skills and knowledge. * Demonstrate a track record and commitment to maintaining updated technical skills and knowledge. * Demonstrate a proficiency in Microsoft Office Suite software. |
| Application Instructions: | There is one adjunct faculty position in this department at SUNY Korea that will begin in Fall 2021. Review of applications will commence in mid-June and decisions will be made by early July. If you are successful in the first round, you will be invited for an interview and a demo lecture will be followed for the successful candidates. The salary and appointment will be based on education level and cumulative experience. Please note a background check is required for appointment to this position. Applications must be submitted to academic.fit@sunykorea.ac.kr. Online applications are strongly encouraged.  Please provide:   * Letter of interest, in English, clearly indicating qualifications for the position * Professional resume and digital portfolio * A minimum of two professional references, including names, titles, addresses, phone numbers, and e-mail contact information * Copy or scan of academic transcript and degree certificate in English from all colleges and universities attended. (Official University Transcripts will be requested at time of hire.)   Application Deadline: June 13th, 2021 (Sunday)  Please note: based on the volume of applications, we may not be able to contact each applicant individually.  Additional information about the Fashion Institute of Technology can be found at: [www.fitnyc.edu](http://www.fitnyc.edu). |
| Diversity Statement | FIT is firmly committed to creating an environment that will attract and retain people of diverse racial and cultural backgrounds. By providing a learning and working environment that encourages, utilizes, respects, and appreciates the full expression of every individual’s ability, the FIT community fosters its mission and grows because of its rich, pluralistic experience. FIT is committed to prohibiting discrimination, whether based on race, national origin, gender, religion, ethnic background, age, disability, marital status, sexual orientation, or any other criterion prohibited by applicable federal, state, or local laws. FIT is committed to providing equal opportunity in employment, including the opportunity for upward mobility for all qualified individuals. |